

The Incoatec Microfocus Source for XRD-Applications

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The Incoatec Microfocus Source $\mu\text{S}^{\text{High Brilliance}}$

The $\mu\text{S}^{\text{High Brilliance}}$, the next generation of Microfocus Sources, includes the latest type of 2-dim beam shaping Montel multilayer mirrors and is available for Cu, Mo, Ag, Cr and Co radiation. When compared to the original μS the new $\mu\text{S}^{\text{High Brilliance}}$ delivers an increase in intensity of about 30% for Cu, 50% for Ag and 60% for Mo due to an improved heat management. The $\mu\text{S}^{\text{High Brilliance}}$ includes all the familiar advantages of the previous μS system: air-cooling, no moving parts and long lifetime without maintenance. It combines all advantages of a sealed-tube system with the superior data quality of conventional rotating anode systems. Furthermore, memory chips are integrated into the tube, the tube mount and optics, thus allowing the recording of the real-time status of the components. This simplifies considerably the installation and change of components and enables assessing the system online, making remote diagnostics faster, better and easier. The $\mu\text{S}^{\text{High Brilliance}}$ is available as a component of diffractometers of Bruker AXS such as the new D8 Discover or VENTURE and also for upgrading existing systems.



The source

- air cooled
- Cu, Mo, Ag, Cr and Co available
- component recognition
- improved safety features
- fully compliant with Machinery Directive 2066/42/EC

Quazar Optics

- 2-dim beam shaping
- collimating or focussing
- patented housing for high stability and easy alignment
- motorized alignment (optional)

Optics	Divergence (mrad)	Focal size (μm)	Flux (10^9 ph/s)	Flux density (10^9 ph/(s \cdot mm 2))
SAXS (Cu)	1.0	800	> 2.1	
Cr	1.0	800	> 1.2	
Co	1.0	800	> 1.5	
SAXS ultra (Cu)	0.5	2000	~ 5.0	
SAXS (Mo)	0.5	650	> 0.16	
Cu	5.1	250	> 7.8	> 6.5
Cr	5.1	330	> 5.0	> 1.5
Co	5.1	280	> 2.0	> 3.0
Mo	4.9	110	> 0.3	> 1.9
Ag	4.9	95	> 0.1	> 0.9

Standard models of the $\mu\text{S}^{\text{High Brilliance}}$ (others on request).

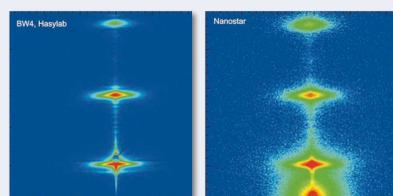


D8 Advance: XRD 2 system with $\mu\text{S}^{\text{High Brilliance}}$ (left). Integrated memory chips store information provided by the manufacturer and during use (right).

μS for Small Angle X-ray Scattering

Grazing Incidence SAXS of thin films

The development of Bruker's NANOSTAR with integrated μS allows measurements, which usually need synchrotron facilities, to be performed in the home-lab. The figures show the results of a Mo/Si multilayer measured with the NANOSTAR and the synchrotron beamline BW4 at the Hasylab. Both measurements clearly show three Bragg sheets. In comparison the NANOSTAR results have a higher background and thus a lower resolution. However, all features required for data processing are visible. This striking result gives the opportunity to plan future experiments without the restriction of beam time. Due to the μS the NANOSTAR now enables a more efficient use of synchrotron beam time and gives the opportunity to envision e.g. time- or temperature-resolved long-term experiments.



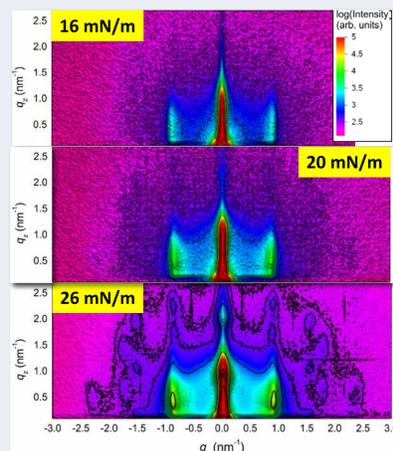
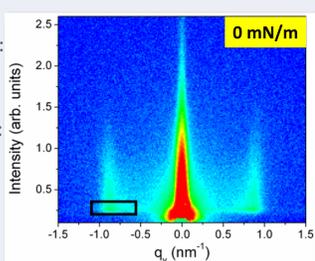
In-situ GISAXS with liquid samples

For rapid GISAXS measurements of liquid samples our μS was combined with a Dectris Pilatus detector. Silver particles on a Langmuir film were analyzed at different surface pressures which were applied by means of a reduction of the surface area. It was possible to study the formation process from unordered islands to ordered layers by increasing the pressure on the surface.



Measurement details:

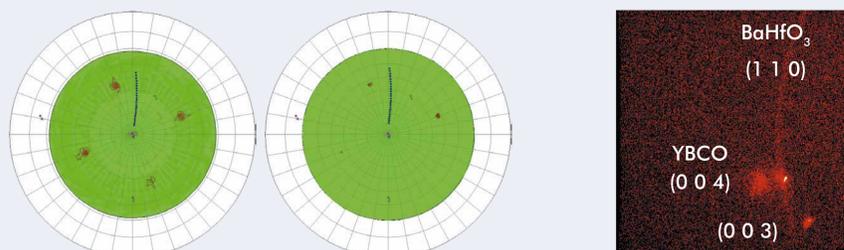
- angle of incidence: 0.2deg
- measurement time: 180 sec
- aperture 350 μm
- the surface was pressed with 0 up to 26 mN/m



Unpressed surface: islands of nanoparticles are swimming on the surface without connection (top)
 Increased surface pressure: intensity increases, islands coalescence (right)
 at 26 mN/m: "crystal" peaks appear, vertical formation of hexagonal layers

μS for Texture Measurements

Sample: BaHfO_3 nanoparticles (10-20 nm) in a YBCO matrix (thin film on SrTiO_3)
 Experimental: Cu- μS + collimating optics in a Bruker D8 GADDS with eulerian cradle and VANTEC2000-detector, total measuring time < 50min.
 Result: the majority of the nanoparticles are randomly incorporated in the YBCO matrix. Nevertheless, it was possible to measure a (1 1 0) pole figure of the epitaxially grown BaHfO_3 fraction, which has a fourfold-symmetry similar to the YBCO film. With this set-up it is possible to carry out a complete pole figure measurement in less than one hour.

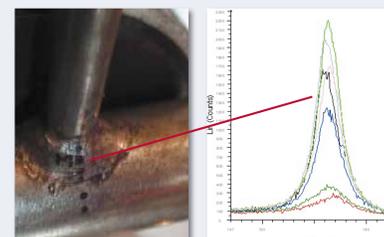
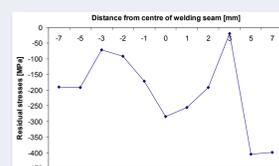


Pole figure of the YBCO (004) reflex (left) and BaHfO_3 (110) reflex (middle). Frame (right) at $2\theta=35^\circ$, $\omega=18.7^\circ$, $\gamma=54.3^\circ$, exposure time 20 seconds. The Scherrer-ring of the BaHfO_3 (1 1 0) peak is visible together with the (0 0 4) and (0 0 3) spots of YBCO.

μS for Cr Radiation: Best for Position Sensitive Stress Analysis

Measurements of samples containing iron are possible by using a 14W Cr- μS without exciting fluorescence radiation. This source with a focussing optics can also be used for position sensitive measurements on steel parts, for example across a welding seam. The spot size of the focal point of the beam is 330 μm . Measurements in steps of 1 mm are possible as shown in the example. The stress profile from this measurement shows the expected characteristics for a weld.

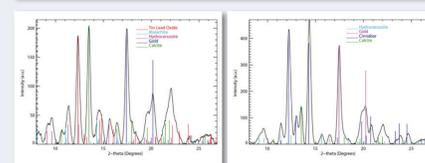
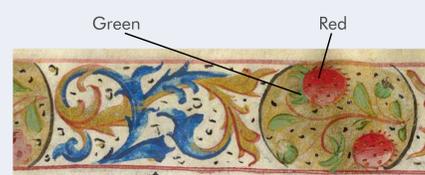
(data from H. and U. Göbel, LabXA, Munich, Germany)



μS for Scanning Microdiffraction

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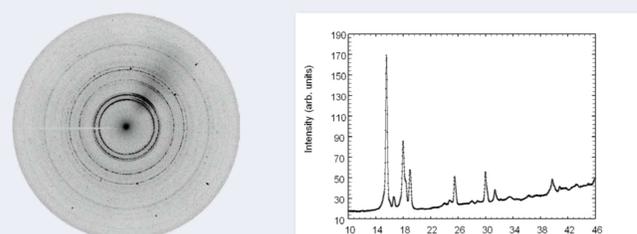
A painting in a medieval manuscript was investigated using a Mo- μS with focusing optics. Within 30 seconds exposure time frames were recorded using a Smart 1000 detector (Bruker AXS) to identify the color pigments. Such investigation allows statements on repairing, repainting or falsification of art objects. With this setup it was possible to scan in an overnight measurement an area of several square millimeters with a resolution of 150 μm . (Data courtesy of F. Vanmeert and K. Janssens, University of Antwerp, Belgium)



Setup for the measurements in transmission geometry (right) and book painting with indicated colors and diffraction pattern of green and red colored regions respectively (left, Mo- μS , 30 s exposure time each).

Measurements in Diamond Anvil Cell with Ag- μS

Due to its high energy of 22.2 keV silver radiation can easily penetrate diamond anvil cells without much absorption. Another advantage is, that more peaks are in the same 2θ -space compared to measurements with radiation of lower energy, e.g. copper or molybdenum. In this example a measurement of a red color pigment, Pigment Red 170, is shown. The measurement was performed at a mardtb with an imaging plate detector mar345 with 20 minutes exposure time.



Frame of pigment red 170 in a diamond anvil cell (left) and an integrated pattern (right) showing the sample and also some peaks from the steel gasket.